D-2 Wet Coating

Representative Organizer Ryoichi ICHINO (Nagoya University) <u>Co-organizer</u> Yuki KAMIMOTO (Nagoya University)

Post	er Sess	on March 30 (Mon.) $11:15 \sim 12:30$
11:15	D2-P-01	Sn/Ag Micro Bump Prepared by Electrochemical Deposition Method at Low Temperature ¹ Chun Liang Lu, ¹ Chih Wei Hsu, ² <u>Ting Jen Hsueh</u> <i>1 DEPARTMENT OF ELECTRICAL ENGINEERING, NATIONAL UNIVERSITY OF TAINAN</i> <i>2 NATIONAL NANO DEVICE LABORATORIES</i>
11:15	D2-P-02	Plasma Electrolytic Treatment of Low Carbon Alloy Steel Using a DC Pulse Power ¹ Jung Hyun Kong, ¹ Masahiro Okumiya, ¹ Yoshiki Tsunekawa, ¹ Tomonori Takeda, ² Ky Youl Yun, ³ Masashi Yoshida, ⁴ S.G Kim <i>1 MATERIALS PROCESSING LABORATORY, TOYOTA TECHNOLOGICAL INSTITUTE</i> <i>2 FACULTY OF ENG. AND GRADUATE SCHOOL OF ENGINEERING, GIFU UNIVERSITY</i> <i>3 DEPT. OF MECHANICAL ENGINEERING, SHIZUOKA INSTITUTE OF SCIENCE AND TECHNOLOGY</i> <i>4 SURFACE TECHNOLOGY & HEAT TREATMENT R&D DEPARTMENT, KOREA INSTITUTE OF INDUSTRIAL TECH.</i>
11:15	D2-P-03	Tribological and Corrosion Behavior of Gear Steels Carburized via Current Heating Technique Atcharawadi Thongon, Chatdanai Boonruang DEPARTMENT OF PHYSICS AND MATERIALS SCIENCE, CHIAG MAI UNIVERSITY
11:15	D2-P-04	Sterilization of Seawater by the Electrolytic-Reduction Treatment ¹ <u>Yongsup Yun</u> , ² Boksoo Kim, ² Junyong Park, ³ Jun Kang, ³ Myeonghoon Lee <i>1 DEVISION OF MARINE SYSTEM ENGINEERING, KOREA MARITIME AND OCEAN UNIVERSITY</i> <i>2 SOULBRAIN NANOTEC CO. LTD.</i> <i>3 DEVISION OF MARINE SYSTEM ENGINEERING, KOREA MARITIME AND OCEAN UNIVERSITY</i>
11:15	D2-P-05	Infrared Spectroscopy of Interaction between Plasmas and Self-Assembled Monolayers <u>Masanori Shinohara</u> , Yuta Yoshida, Naoki Maruno, Yujiro Taniguchi, Yamato Nakano, Kazuki Ito, Yoshinobu Matsuda, Hiroshi Fujiyama <i>GRADUATE SCHOOL OF ENGINEERING, NAGASAKI UNIVERSITY</i>
11:15	D2-P-06	Development of Corrosion-Resistant Coating of Mg Alloy with Maintaining Metallic Texture ^{1,2} <u>Min-Ju Park</u> , ¹ Hohyeong Kim, ^{1,2} Sena Na, ¹ Jae Young Park <i>I SURFACE TECHNOLOGY R&BD GROUP, KOREA INSTITUTE OF INDUSTRIAL TECHNOLOGY</i> <i>2 DEPARTMENT OF MATERIALS SCIENCE AND ENGINEERING, INHA UNIVERSITY</i>
11:15	D2-P-07	Fabrication and Characterization of Porous TiO₂ Films for Photocatalytic Removal of VOCs ¹ <u>Hohyeong Kim</u> , ^{1,2} Min-Ju Park, ¹ Minsu Lee, ¹ Jae Young Park <i>I SURFACE TECHNOLOGY R&BD GROUP, KOREA INSTITUTE OF INDUSTRIAL TECHNOLOGY</i> <i>2 DEPARTMENT OF MATERIALS SCIENCE AND ENGINEERING, INHA UNIVERSITY</i>
11:15	D2-P-08	Study on Characteristic of Ni-Co-SiC Composite Plating in Accordance with Types of Metallic Salts H.K.Lee, <u>J.M.Jeon</u> <i>surface technology r&bd group, incheon regional division, korea institute of industrial technology</i>
11:15	D2-P-09	Ultrasonic Effect on the Pd Activation Step for Electroless Cu Coating C.M.Lee, J.Y.Hur, <u>H.K.Lee</u> SURFACE TECHNOLOGY R&BD GROUP, INCHEON REGIONAL DIVISION, KOREA INSTITUTE OF INDUSTRIAL TECHNOLOGY

11:15	D2-P-10	Study on Modification of PET Surface by Ultraviolet Irradiation for Electroless Copper Deposition Utilizing Silver Catalyst
		H.K.Lee, J.Y.Hur, <u>G.H.Lee</u>
		SURFACE TECHNOLOGY R&BD GROUP, INCHEON DIVISION, KOREA INSTITUTE OF INDUSTRIAL TECHNOLOGY
11:15	D2-P-11	Cavitation Erosion Behavior of 5083-O Al Alloy Surface-Modified by Plasma Electrolytic Oxidation Process
		Jung-Hyung Lee, Seong-Jong Kim
		DIVISION OF MARINE SYSTEM ENGINEERING, MOKPO MARITIME UNIVERSITY
11:15	D2-P-12	Microstructural and Electrochemical Characteristics of Oxide Film with Plasma Electrolytic Oxidation of Al-Mg Alloy
		Jung-Hyung Lee, Seong-Jong Kim
		DIVISION OF MARINE SYSTEM ENGINEERING, MOKPO MARITIME UNIVERSITY
11:15	D2-P-13L	Maunfacturing of Functional Probe Pin through Electrolytic Ni Alloy Electroplating <u>Joo-Yul Lee</u> , Yongsoo Jeong
		DEPARTMENT OF ELECTROCHEMISTRY LABORATORY, KOREA INSTITUTE OF MATERIALS SCIENCE
11:15	D2-P-14L	Plasma Electrolytic Oxidation of Mg
		1 ADVANCED MATERIALS ENGINEERING, KOREA UNIVERSITY OF SCIENCE AND TECHNOLOGY 2 SURFACE ENGINEERING DIVISION, KOREA INSTITUTE OF MATERIALS SCIENCE
11:15	D2-P-15L	Chemical Dry Etching of Si Using F₂ and NO₂ Gases at Elevated Temperature <u>Satomi Tajima</u> , Toshio Hayashi, Kenji Ishikawa, Makoto Sekine, Masaru Hori
		PLASMA NANOTECHNOLOGY RESEARCH CENTER, GRADUATE SCHOOL OF ENGINEERING, NAGOYA UNIVERSITY